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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/803,083	03/08/2001	Thomas P. Glenn	G0049M	8521

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EXAMINER

MALDONADO, JULIO J

ART UNIT

PAPER NUMBER

2823

DATE MAILED: 04/04/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)
	09/803,083	GLENN ET AL.
	Examiner	Art Unit
	Julio J. Maldonado	2823

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on ____.

2a) This action is **FINAL**. 2b) This action is non-final.

3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 1-21 is/are pending in the application.

4a) Of the above claim(s) ____ is/are withdrawn from consideration.

5) Claim(s) ____ is/are allowed.

6) Claim(s) 1-21 is/are rejected.

7) Claim(s) ____ is/are objected to.

8) Claim(s) ____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.

10) The drawing(s) filed on ____ is/are: a) accepted or b) objected to by the Examiner.

Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

11) The proposed drawing correction filed on ____ is: a) approved b) disapproved by the Examiner.

If approved, corrected drawings are required in reply to this Office action.

12) The oath or declaration is objected to by the Examiner.

Priority under 35 U.S.C. §§ 119 and 120

13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).

a) All b) Some * c) None of:

1. Certified copies of the priority documents have been received.

2. Certified copies of the priority documents have been received in Application No. ____.

3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).

a) The translation of the foreign language provisional application has been received.

15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

Attachment(s)

1) Notice of References Cited (PTO-892)

2) Notice of Draftsperson's Patent Drawing Review (PTO-948)

3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 4.

4) Interview Summary (PTO-413) Paper No(s). ____.

5) Notice of Informal Patent Application (PTO-152)

6) Other: ____.

DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

2. The term "sufficiently" in claim 4 is a relative term, which renders the claim indefinite. The term "sufficiently" is not defined by the claim, the specification does not provide a standard for ascertaining the requisite degree, and one of ordinary skill in the art would not be reasonably apprised of the scope of the invention. If applicants intends any particular optical transmittance, it must be clearly recited.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

4. Claims 1,7, 9 and 10-13 are rejected under 35 U.S.C. 102(b) as being anticipated by Wojnarowsky (U.S. 5,888,884).

Wojnarowsky (Figs.1-7 and 9) teaches a method to form alignment marks (90) comprising aligning a drilling device at a first intersection of a first scribe line and a second scribe line coupled to a first surface (32) of a substrate (30); drilling through said substrate (30) at said first intersection with said drilling device from said first surface (32) of said device from said first surface to a second surface (34) of said substrate to form an alignment mark (90); aligning a saw (400) with said first scribe line using said

alignment mark (90), wherein said saw (400) comprises a laser saw and cutting said substrate (30) comprises cutting on the scribe lines from said second surface (34) (see Fig.7); and singulate electronic components (36) of said substrate (30), wherein said electronic components comprises integrated circuits (column 6, line 20 – column 8, line 65).

Claim Rejections - 35 USC § 103

5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claims 2-6 and 14-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wojnarowsky ('884) in view of Roberts Jr. et al. (U.S. 5,362,681).

Wojnarowsky (Figs.1-7 and 9) teaches a method to form alignment marks (90) comprising aligning a drilling device at a first intersection of a first scribe line and a second scribe line coupled to a first surface (32) of a substrate (30); drilling through said substrate (30) at said first intersection with said drilling device from said first surface (32) of said device from said first surface to a second surface (34) of said substrate to form an alignment mark (90); aligning a saw (400) with said first scribe line using said alignment mark (90), wherein said saw (400) comprises a laser saw and cutting said substrate (30) comprises cutting on the scribe lines from said second surface (34) (see Fig.7); and singulate electronic components (36) of said substrate (30), wherein said

electronic components comprises integrated circuits (column 6, line 20 – column 8, line 65).

Wojnarowsky fail to teach coupling a front-side surface of a wafer to an interior surface of a transparent wafer support; optically recognizing a scribe grid coupled to said front-side surface of said wafer through said wafer support, wherein said support protects the front surface of said substrate; and washing said substrate to remove contaminants generated during said cutting. However, Roberts Jr., et al. (Figs.2-5) in a related method to singularize a semiconductor wafer teach coupling a front-side surface of a wafer (32) to an interior surface of a transparent wafer support (26); optically aligning the wafer through said wafer support, wherein said support protects the front surface of said substrate; and washing said substrate to remove contaminants generated during said cutting (column 7, line 33 – column 9, line 7). Therefore, it would have been obvious to one of ordinary skill in the art to combine the teachings of Roberts Jr. et al. and Wojnarowsky to enable the steps of coupling a front-side surface of a wafer to an interior surface of a wafer support; and optically recognizing a scribe grid coupled to said front-side surface of said wafer through said wafer support, and furthermore because this would result in a method of separating individual dies that will provide better protection to the microstructures formed in said die (column, 3, lines 37 – 61).

7. Claims 2-6 and 14-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wojnarowsky ('884) in view of Summerer (U.S. 6,537,836 B2).

Wojnarowsky substantially teaches all aspects of the invention but fails to show shining light of an angle to said second surface of said substrate to enhance recognition of said alignment mark. However, Summerer (Fig.1) in a related method for alignment of substrates teaches shining light of an angle to a surface of a substrate (12) to detect alignment marks (column 2, lines 4 – 31). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use the alignment detection method as taught by Summerer to enhance recognition of an alignment mark in a second surface of a substrate in Wojnarowsky, since illuminating methods are well-known in the art to properly align a semiconductor substrate (column 1, lines 11 – 28).

Conclusion

8. Papers related to this application may be submitted directly to Art Unit 2823 by facsimile transmission. Papers should be faxed to Art Unit 2823 via the Art Unit 2823 Fax Center located in Crystal Plaza 4, room 3C23. The faxing of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (15 November 1989). The Art Unit 2823 Fax Center number is **(703) 305-3432**. The Art Unit 2823 Fax Center is to be used only for papers related to Art Unit 2823 applications.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to **Julio J. Maldonado** at **(703) 306-0098** and between the hours of 8:00 AM to 4:00 PM (Eastern Standard Time) Monday through Friday or by e-mail via julio.maldonado@uspto.gov. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri, can be reached on (703) 306-2794.

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Any inquiry of a general nature or relating to the status of this application should
be directed to the **Group 2800 Receptionist at (703) 308-0956.**

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JMR
3/25/03



George Fourson
Primary Examiner